

Supporting Information

Highly Sensitive and Specific Screening of EGFR Mutation Using a PNA Microarray-based Fluorometric Assay based on Rolling Circle Amplification and Graphene Oxide

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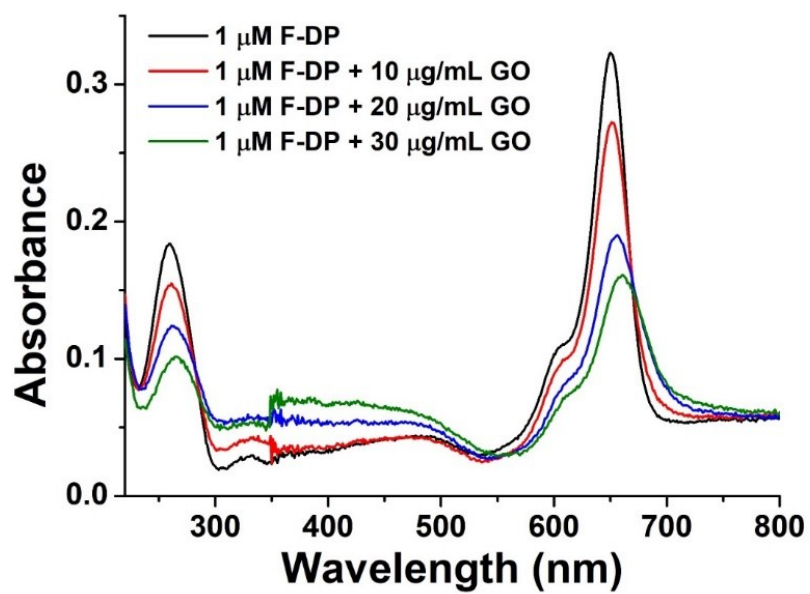


Fig. S1. UV/vis absorption spectra of 1 μM F-DP solutions in the absence and presence of different concentrations of GO.